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Metal-semiconductor Phase-transition in WSe_{2(1-x)}Te_{2x} Monolayer

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In order to produce tunable high-performance electronic devices, bandgap engineering by alloying different semiconductors have been demonstrated in the bulk semiconductors, [1-2] such as $Al_xGa_{1-x}As$ for quantum structures, $CuIn_xGa_{1-x}Se_2$ for solar cells, $In_xGa_{1-x}N$ for light emitting diodes, and $Hg_xCd_{1-x}Te$ for infrared detectors, respectively. Recently, the band gap engineering has been realized in monolayer ternary dichalcogenides (TMDs) with 2H phase.



For example, alloy MoS_{2x}Se_{2(1-x)} monolayer^[3-6] with tunable chemical composition have been realized, as well as the $W_xMo_{1-x}S_2$ and $W_xMo_{1-x}Se_2$. [6-9] However, only a few hundred millielectron volts (meV) can be tuned for these ternary layers, ~ 300 meV for W_xMo_{1-x}S₂ and ~500 meV forMoS_{2x}Se_{2(1-x)}, $[^{3-7}]$ to be precise. Recently, the transition from semiconducting to metallic 2D MoTe₂ has been reported by realizing a ultra-low contact resistance at the heterostructured interface of 2H and 1Td MoTe₂.^[10] These work inspire the synthesis of novel 2D materials with metal-semiconductor transition for applications in nanoelectronics and nanophotonics. Therefore, a unique ternary 2D material with tunable semiconductor-metal transition, preferably controlled by its chemical composition or ternary ratio, are urgently required to fill such gap. It is well known that WSe2 is a p-type 2D semiconductor with an indirect band gap (1.2 eV) for bulk and direct band gap (1.65 eV) for monolayer, respectively. [11-16] It generally shows 2H crystal structure. On the other hand, WTe₂ is a semimetal with 1Td crystal structure, displaying an extremely large magnetoresistance effect in its diamagnetic single crystals.^[17-21] The marriage of these two materials suggests a possible route for creating a ternary TMD layer to realize a semiconductor-metal phase transition.

In this work, ternary WSe_{2(1-x)}Te_{2x} (x = 0–1) have been synthesized via chemical vaper transport (CVT) in a one-step synthesis, which exhibit two distinct structures (2H and 1Td, corresponding to semiconductor and metal, respectively). Three regions (2H phase, the coexistence of 2H and 1Td phase, and 1Td phase) have been identified in the complete composition of the alloy. Energy dispersive X-ray (EDX) and X-ray photoelectron spectroscopy (XPS) characterization confirm the existence of W, Se and Te with a controlled ratio. Atomic resolution scanning transmission electron microscope (STEM) images further reveal the atomic structure of the alloyed monolayers with different Te alloying concentrations and how they evolve from 2H to the distorted 2H phase, and finally reshape into 1Td phase. Raman spectra identify different phases (2H and 1Td phases) and



composition variations in the $WSe_{2(1-x)}Te_{2x}$ alloy. The optical band gap of 2H $WSe_{2(1-x)}Te_{2x}$ monolayer have been estimated by photoluminescence (PL) spectra. The electrical properties of atomic layered 2H WSe_2 , 2H $WSe_{1.4}Te_{0.6}$, 1Td $WSe_{0.6}Te_{1.4}$ and 1Td WTe_2 FETs have been systematically studied, which indicate 2H phase is p-type semiconductor and 1Td phase is a metal. Additionally, the p-type $WSe_{2(1-x)}Te_{2x}$ FETs exhibit excellent electronic characteristic with effective hole carries mobility up to $46 \text{ cm}^2V^{-1}s^{-1}$ and on/off ratios up to 10^6 .

The single crystals of $WSe_{2(1-x)}Te_{2x}$ (x = 0–1.0) alloys have been synthesized by the method of chemical vaper transport (CVT) with a small amount of iodine (I) as the transport agency, shown in Figure S1. It is noted that 2H and 1Td WSe_{2(1-x)}Te_{2x} single crystals form into platelets and strips, respectively, which are in agreement with their own crystalline space groups (hexagonal $P6_3/mmc$ and orthorhombic $Pmn2_1$, respectively), as shown in Figure 1a. [11, ^{17]} The crystal structure of 2H WSe_{2(1-x)}Te_{2x} is similar to 2H MoS₂. It consists of the WSe₆ or WSe/Te₆ triangular prism layers bonded together by weak van der Waal's forces, as shown in Figure 1b. While 1Td WSe_{2(1-x)}Te_{2x} compose of the WTe₆ or WSe/Te₆octahedra linked with each other by sharing the Te-Te edges. Its crystal structure shows a distorted variant of the 1T CdI₂ type, regard as 1Td TMD structure shown in Figure 1c. As summarized in Figure 1d, the 2H and 1Td WSe_{2(1-x)}Te_{2x} can be produced by tuning the concentration of Te from 0 to 100% where x = 0-0.4 for 2H structure, x = 0.5 and 0.6 for 2H and 1Td structures, and x = 0.7-1.0for 1Td structure, confirmed by Energy dispersive X-ray spectroscopy (EDX) (Figure S2), Xray photoelectron spectroscopy (XPS) (Figure S3, S4, S5 and S6) and the powder X-ray diffraction (XRD) (Figure 1d and S7). It is worth noting that an intermediate state appears with two phases (1Td and 2H) when the concentration of Te increases.

The atomic structure of the layered $WSe_{2(1-x)}Te_{2x}$ alloys have been further studied by Z-contrast scanning transmission electron microscopy (STEM). Since the image intensity in Z-contrast STEM imaging is directly related to the atomic number of the imaged species in thin flakes, we only examine the alloyed monolayers exfoliated from the bulk. Figure 2 shows four



typical monolayers with different Te concentration and phases, including 2H WSe₂ (x = 0, Figure 2a), 2H WSe_{2(1-x)}Te_{2x} (x = 0.5, Figure 2b), 1Td WSe_{2(1-x)}Te_{2x} (x = 0.5, Figure 2c) and 1Td WTe₂ (x = 1, Figure 2d). In pristine WSe₂ shown in Figure 2a, the monolayer maintains a hexagonal lattice shape, with alternating bright and less bright spots as W and Se₂ atomic columns, respectively, similar to the other reports. The Fast Fourier Transform (FFT) pattern further confirms the hexagonal nature of the lattice. Figure 2b shows a monolayer region exfoliated from 2H WSe_{1.0}Te_{1.0} bulk crystal, which displays a hexagonal lattice shape (confirmed by FFT pattern) but exhibits distinguishable atomic column intensity from the pristine WSe₂. Te₂ columns (the brightest spots in Figure 2b) maintain higher intensity than the W columns due to their heavier atomic weight, while Te+Se and Se₂ columns have lower intensity than W, which confirms the successful in-lattice substitution of Te atoms in the Se sites. It is notable that such intensity distribution is similar to the ternary MoS_{2x}Se_{2(1-x)} alloys. Is

Figure 2c shows a monolayer region exfoliated from the 1Td phase bulk crystal with similar chemical composition in Figure 2b. The atomic resolution image confirms the transition from the 2H phase to 1Td, as verified by the zigzag-like chains. FFT pattern further shows the periodicity of the lattice change from hexagonal to orthorhombic. Te atoms, which can be distinguished by its higher intensity than Se atoms, are found to be substituted into either two asymmetric sites in the orthorhombic unit cell of the 1Td phase, as indicated by the structural model. As shown in Figure 2d, further increasing the Te concentration to 100% results in WTe₂ in a perfect 1Td phase where the zigzag W–Te and Te chains have uniform intensity distribution along the chain direction without much intensity variance, in sharp contrast to Figure 2c. Moreover, TEM characterizations of thick flakes of WSe_{2(1-x)}Te_{2x} with different Te concentrations are also provided in Figure S8. These results confirm the high quality of our as-synthesized bulk crystals. It is notable that although the high-resolution STEM results confirm the atomic structures of the co-existed 2H and 1Td phase in different



WSe_{1.0}Te_{1.0} bulk crystal, we didn't observe any intrinsic defect (such as dislocations or grain boundaries) except alloyed Te atoms and electron-induced vacancies in both the 2H and 1Td phases, neither phase segregation in the same flake. These results suggest that the phase transition may occur at the very beginning of the growth and continue to form perfect 2H or 1Td lattice structures depending on the initial nucleation. However, it is interesting that phase mixing (2H and 1Td) occurs at some critical range of Te alloy concentration, which requires more effort to investigate the phase transition mechanism inside these WSe_{2(1-x)}Te_{2x} alloys. This will be the topic of our future study of this material system.

Raman spectra of monolayer and bulk of $WSe_{2(1-x)}Te_{2x}$ (x = 0–100%) single crystals have been collected to confirm the phase transformations in the sample with different Te compositions. The WSe_{2(1-x)}Te_{2x} monolayers are prepared by micromechanical exfoliation of WSe_{2(1-x)}Te_{2x} single crystals and transfer their atomic layered samples on SiO₂/Si substrate (280 nm oxide layer) using the Scotch tape. The thicknesses of all the samples are identified by atomic force microscopy (AFM), as shown in Figure S10. Raman vibration modes dependent on the concentration of Te are mapped in Figure 3a and 3b, excited by 532 nm laser. For comparison, the typical Raman spectra of $WSe_{2(1-x)}Te_{2x}$ for $x=0,\,0.1,\,0.2,\,0.3,\,0.4$ and 0.5 are plotted in Figure 3c and 3d for monolayer and bulk samples, respectively. For WSe₂, the two characteristic peaks E^{1}_{2g} and A_{1g} for monolayer and bulk WSe₂ are 248.6 and 260.9 cm⁻¹, 245.9 and 255.8 cm⁻¹, respectively, in agreement with previous report. [12, 14, 23-25] Increasing the concentration of Te softens these two peaks and make a red-shift, as shown in Figure 3c, which can be contributed to the high frequency vibration due to the heavy Te dopant. This phenomenon is also observed in other TMD alloy such as Se alloyed MoS₂. The intensity of the peaks becomes very weak. Meantime, for monolayer sample, the peak locates around 120 cm⁻¹ appears. It is also noticed that in both monolayer and bulk sample, after alloying Te, E¹_{2g} and A_{1g} vibration modes split into three modes as displayed in Figure 3c and 3d.



As we mentioned above (Figure 1), co-existence of 2H and 1Td phases occurs if the Te mole fraction in WSe_{2(1-x)}Te_{2x} alloy is between 0.5–0.6, while only 1Td phase can be found in the samples when x > 0.6, a strong evidence that 2H phase is completely translated into 1Td phase in order to realize the translation from semiconductor to metal. In other words, the highest Se alloyed level in Te sites for 1Td WSe_{2(1-x)}Te_{2x} alloy is 0.4 in mole fraction. Such upper limit of Se dopant will be crucial for the studies of WTe₂ based Wyle semimetals via chalcogen alloying. [26-28] Also, it is interesting to examine the evolution of Raman signal of 1Td WSe_{2(1-x)}Te_{2x} (x \geq 0.5). Figure 4 shows the intensity of Raman vibration modes dependency on the mole fraction of Te and typical Raman spectra for monolayer and bulk 1Td WSe_{2(1-x)}Te_{2x} alloy, respectively. As shown in Figure 4a and 4b, two main vibration modes A_1^5 and A_1^2 (denoted as A_1^5 and A_1^2 , respectively) are found for monolayer and bulk WTe₂ are 162.2 and 213.3 cm⁻¹, 161.17 and 208.60 cm⁻¹, respectively, along with some weak peaks below 150 cm⁻¹, which are in agreement with the reported values^[18-19]. In addition, in order to clearly shown the signatures of the Raman signal, typical Raman spectra are plotted in Figure 4c and 4d (x = 0.5, 0.6, 0.7, 0.8, 0.9 and 1.0). Compared with the Raman peaks of bulk WTe₂, the peaks from monolayers show considerable blue shifts around 10 cm⁻¹. More interestingly, Raman spectra of 1Td $WSe_{2(1-x)}Te_{2x}$ alloys with x = 0.5 and 0.6 display similar profiles. Such phenomenon is also observed in 2H $WSe_{2(1-x)}Te_{2x}$ (x = 0.5 and 0.6) alloys. Therefore, it is reasonable to speculate that $WSe_{2(1-x)}Te_{2x}$ alloys with x = 0.5 and 0.6 (mixture of 2H and 1Td) are intermediate states when the semiconducting 2H alloys transits to the metallic 1Td alloys. This is also supported by our STEM images in Figure 2b and 2c.

Engineering the band gap of 2D materials make them the reality for the wide spectrum of applications. Recently, the carbon-doped boron nitride (BCN) films have been intensively studied so that ternary 2D materials become a promising way. However, the phase separation in BCN film at high temperature make it a challenge to produce homogeneous BCN atomic layers with precious control in the composition, mainly due to the lattice mismatch of h-BN



and graphene which is not low enough (~ 2.7%). TMDs, consisting of a few families with similar crystal structure make it possible to produce the homogeneous 2D ternary monolayers. TMD alloys, such as Se alloyed MoS₂, W alloyed MoS₂, etc, have been reported in the past few years. [3-9, 29] But no TMD ternary can provide a transition from semiconductor to metal like what have been reported in BCN films and bulk materials. The WSe_{2(1-x)}Te_{2x}, consisting of semiconducting WSe_2 (x = 0) and metallic WTe_2 (x = 1), make it possible to achieve a much large tunable range of band gap. Photoluminescence (PL) is a good tool to evaluate the optical gap of semiconducting materials, especially band gaps evolution in 2H WSe_{2(1-x)}Te_{2x} (x = 0-0.6). The photoluminescence (PL) spectra of monolayer samples excited with a 532 nm laser are collected and shown in Figure 5a. All monolayer 2H WSe_{2(1-x)}Te_{2x} show the emission bands, and the spectral peak continuously shifts from 744 nm (pure WSe₂) to 857 nm (near infrared). For 1Td sample, as expected, no PL signal is detected when $x \ge 0.6$. Figure 5b plots the optical gap vs mole fraction of Te for monolayer WSe_{2(1-x)}Te_{2x}. The band gaps are continuously shifted from 1.67 eV (pure WSe₂) to 1.44 eV. Interestingly, it can be found that the optical gaps are similar when x = 0.5 and 0.6, indicating the highest concentration of Te dopant in 2H WSe_{2(1-x)}Te_{2x} alloy is 0.6, which is well agreement with the Raman data. At the same time, the optical gap directly changes from 1.44 eV (2H semiconductor) to 0 eV (1Td metal) in this regime. The optical gaps are 0 eV when x > 0.6, confirming that the WSe_{2(1-x)}Te_{2x} alloys undergo a phase transition from semiconductor (2H phase) to metal (1Td phase). The band gaps of 2H $WSe_{2(1-x)}Te_{2x}$ (x = 0–0.6) monolayers, bilayers and bulk are calculated in Figure S11, basically consistent with our experimental result. In addition, the calculated results also show 2H Te alloyed WSe₂ monolayer is a directgap semiconductor and 1Td WTe2 monolayer is metallic (Figure S12 and S13). Interestingly, the strong optical second harmonic generation (SHG) are found in 2H WSe₂, 2H WSe_{1.8}Te_{0.2}, 2H WSe_{1.4}Te_{0.6} and 2H WSe_{1.2}Te_{0.8}monolayers (Figure S14), which show the break of inversion symmetry is happen in monolayer. With the increase of the mole fraction of Te, the



intensities of SHG become weaker, which may beascribed to the differences of the polarization or the absorbency of the samples with the different concentration of Te. The SHG polarization dependence of 2H WSe₂ and 2H WSe_{1.4}Te_{0.6} monolayers (Figure S15 and S16) are also investigated, which show the samples display three-fold rotational symmetry, in accordance with the D_{3h} symmetry.^[30-32]

The FET devices based bilayer 2H WSe_{2(1-x)}Te_{2x} (x = 0 and 0.3) and 1Td WSe_{2(1-x)}Te_{2x} (x = 0.7 and 1) have been fabricated SiO₂/Si (280 nm oxide layer) substrate in order to further confirm the semiconducting 2H phases and metallic 1Td phases. The Ti/Au electrodes are deposited by e-beam evaporation after photolithography (Figure S17). The optical images of devices are shown in the center of Figure 6. The current–voltage (I_{ds} – V_{ds}) curve and the transfer characteristics (I_{ds} – V_{bg}) of the WSe_{2(1-x)}Te_{2x} transistors are displayed in Figure 6 a–g. By increasing the alloyed level of Te from 0 to 0.3, the drain current increases from around 1.7 nA to 10 nA at a drain voltage of 2V and no gating voltage. The transfer characteristics clearly show a p-type semiconducting behavior for both samples, consistent with the theoretical results and previous literatures. [12-13, 33] The mobility of the carriers can be calculated by $\mu = \frac{L}{W \times (\varepsilon_0 \varepsilon_r/d)} \times \frac{dI_{ds}}{dV_G} \times \frac{1}{V_{ds}}$, where L, W and d denote the channel length, width

and the thickness of SiO₂ layer (285 nm in our devices), respectively. [34] V_{ds} , I_{ds} and V_{b} denote the source–drain bias, current, and bottom gate voltage in the linear region in the I_{ds} – V_{g} curve. ε_{0} and ε_{r} are the vacuum dielectric constant and the dielectric constant of SiO₂ ($\varepsilon_{r} = 3.9$), respectively. The calculated mobility and on/off ratio of bilayer 2H WSe_{2(1-x)}Te_{2x} for x = 0 and 0.3 are 10 cm²V⁻¹s⁻¹ and 10⁶, 46 cm²V⁻¹s⁻¹ and 10⁶, respectively. For x = 0.7 and 1.0, as expected, no drain current dependency is found on the gating voltage, suggesting that 1Td WTe₂ and WSe_{0.6}Te_{1.4} are metallic. It is also noticed that, for x = 0.7, the drain current is around 20 nA at a drain voltage of 2V. For x = 1.0, that is pure WTe₂, the drain current increases more than 3 orders of magnitude, reach to around 40 μ A. It indicates that the



metallic behavior of WTe₂ could be considerably impacted by alloying Se. In addition, the plots of the resistance with the dependence of temperature (Figure S18) also confirm that 2H $WSe_{2(1-x)}Te_{2x}$ (x = 0 and 0.3) are semiconductors and 1Td $WSe_{2(1-x)}Te_{2x}$ (x = 0.7 and 1) are metals because the resistances decrease with increasing temperature for the former, but increasing temperature for the latter.

In conclusion, the phase transition of TMD monolayer from semiconductor to metal has been demonstrated by alloying Te into tungsten diselenide. Using one-step chemical vaper transport (CVT), the complete composition of $WSe_{2(1-x)}Te_{2x}$ (x = 0-1) alloys are obtained, which exhibit distinguishable semiconducting 2H and metallic 1Td phase. Three regions (2H phase, the coexistence of 2H and 1Td phase, and 1Td phase) are identified in the complete composition $WSe_{2(1-x)}Te_{2x}$ (x = 0-1) alloy using Energy dispersive X-ray spectroscopy (EDXS) and Raman spectroscopy. STEM images clearly confirm the semiconducting and metallic WSe_{2(1-x)}Te_{2x} alloys showing the hexagonal and orthorhombic lattices, respectively, and the random distribution nature of the Se and Te atoms arrangements in these alloys is also found. The photoluminescence (PL) spectra show that the optical band gaps of the WSe₂₍₁₋ _{x)}Te_{2x} monolayer can be tuned from 1.67 eV to 1.44 eV (2H semiconductor) and drop to 0 eV (1 Td metal). Additionally, WSe_{2(1-x)}Te_{2x} atomic layer based FET devices confirm that 2H phase is p-type semiconductor but 1Td phase is metal. It is noted that the p-type bilayer 2H WSe₂ and 2H WSe_{1.4}Te_{0.6} field-effect transistors exhibit excellent electronic characteristic with effective hole carries mobility up to 10 and 46 cm²V⁻¹s⁻¹ and on/off ratios up to 10⁶, respectively. These band gap engineering 2D structures could open up an exciting opportunity for not only probing their fundamental physical properties in 2D such as new type of Wyle semimetals effect functional and spin Hall but diverse applications in electronic/optoelectronic devices.

Experimental



Synthesis and mechanical exfoliation of $WSe_{2(1-x)}Te_{2x}$ (x = 0-1) single crystals: Single crystals of $WSe_{2(1-x)}Te_{2x}$ (x = 0-1) were prepared by the method of chemical vapor transport (CVT) with iodide as the transporting agency. The stoichiometric amounts of high purity W, Te and Se with the weight of 0.3 g and 40 mg iodide were sealed in an evacuated 20 cm-long quartz tube under vacuum at 10⁻⁶Torr, which was placed in a three-zone furnace. The reaction zone was pretreated at 850 °C for 30 h with the grown zone at 900 °C, preventing the transport of the samples. The reaction zone was then programed at a higher temperature of 1010 °C with the growth zone at a lower temperature of 900°C for three days to provide a temperature gradient for the growth of single crystal. Finally, the furnace was naturally cooled down to room temperature and the single crystal of $WSe_{2(1-x)}Te_{2x}$ (x = 0-1)can be collected in the growth zone. 2H and 1Td WSe_{2(1-x)}Te_{2x} single crystals show different shapes with the platelet and ribbon, respectively, shown in Figure 1a. Monolayer $WSe_{2(1-x)}Te_{2x}$ (x = 0-1) were mechanically exfoliated from bulk WSe_{2(1-x)}Te_{2x} single crystals and transferred to a silicon substrate with a 280 nm thick silica layer using the scotch tape-based mechanical exfoliation method, which was widely employed for preparation of monolayer graphene and transitional metal dichalcogenides (TMD).

TEM sample preparations and image simulations: The synthesis of WSe_{2(1-x)}Te_{2x} (x = 0.5–0.6) yielded out samples with two distinct morphologies (2H and 1Td phase). We fabricated the TEM samples of 2H and 1Td phases by exfoliating the corresponding bulk crystals (different shape) separately, and then transferred the exfoliated flakes onto Au grid with carbon film via a conventional wet-transfer method with the assistance of PMMA. The Z-contrast STEM imaging were done with a modified JEOL 2100F with delta probe corrector, which corrects the aberration up to 5th order, resulting in a probe size of 1.4 A. The imaging was conducted at an acceleration voltage of 60 kV. The convergent angle for illumination is about 35 mrad, with a collection detector angle ranging from 62 to 200 mrad.



The fabrication and measurements of the devices: The devices were fabricated by photolithography and Ti/Au or Ti/Cr (20nm/80nm) as contact electrodes were deposited using electron-beam evaporation. The channel lengths and widths of the fabricated devices are 6 and 7 μm for 2H WSe₂, 8 and 5 μm for 2H WSe_{1.4}Te_{0.6}, 6 and 4 μm for 1Td WSe_{0.6}Te_{1.4}, and 6 and 5 μm for 1Td WTe₂. The final devices were annealed at 400°C for 2 h with the protection of nitrogen in order to remove resist residues and enhance the metallic contacts. Electrical characterization was performed by current–voltage measurements on a probe station equipped a semiconductor characterization system Agilent B1500A.

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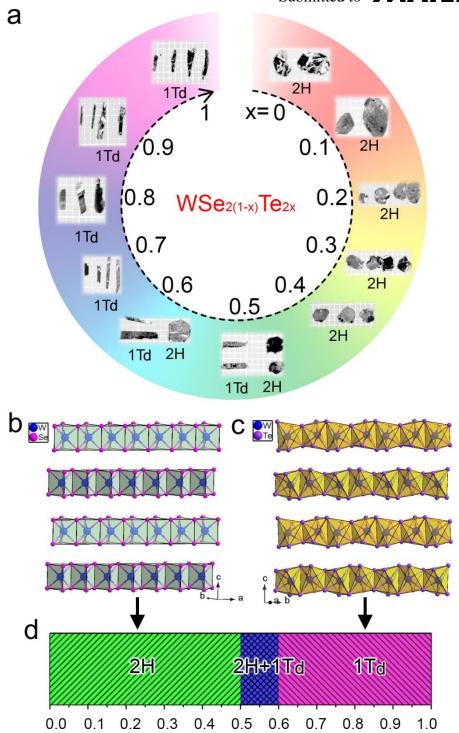


Figure 1. Morphologies of as-grown WSe_{2(1-x)}Te_{2x}(x = 0-1) alloys. (a) Photographs of asgrown WSe_{2(1-x)}Te_{2x} (x = 0-1) single crystals on the millimeter-grid paper, and 2H and 1Td types TMD alloys show circularly platy and bar shapes, which are in agreement with hexagonal and orthorhombic crystal systems, respectively. (b) The crystal structure of 2H WSe₂. (c)The crystal structure of 1T' WTe₂.(d) Different phases with dependence of concentration x in WSe_{2(1-x)}Te_{2x}.

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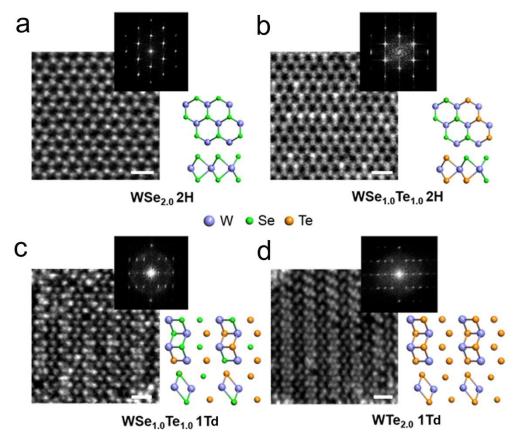


Figure 2. Atomic resolution STEM characterization of WSe_{2(1-x)}Te_{2x} (x = 0–1) alloyed monolayers with different Te concentration. (a–d)Z-contrast STEM images showing the atomic structure of pristine WSe₂ monolayer in 2H phase (a), alloyed WSe_{1.0}Te_{1.0} monolayer in 2H phase, alloyed WSe_{1.0}Te_{1.0} monolayer in 1Td phase and monolayer WTe₂ in 1Td phase. Corresponding FFT patterns are shown in the inset. Te₂, Te+Se and Se₂ atomic columns in the 2H phase, as well as the Te and Se atoms in the 1Td phase, can be distinguished by image intensity. The atomic models are just for schematic purpose. Scale bar: 0.5 nm



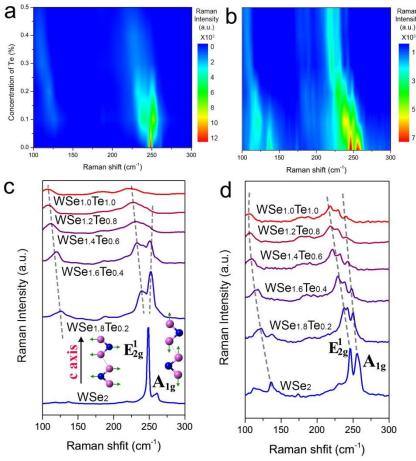


Figure 3. The Raman characterization of bulk and monolayer 2H WSe_{2(1-x)}Te_{2x} (x = 0–0.6) alloys. Raman intensity of monolayer (a) and bulk(b) 2H WSe_{2(1-x)}Te_{2x} (x = 0–0.6) alloys with the different Te compositions. Raman spectra of monolayer (c) and bulk (d)2H WSe_{2(1-x)}Te_{2x} (x = 0–0.6) alloys. The intensities of the W–Se related modes (E¹_{2g(W–Se)} and A_{1g(W–Se)}) gradually decrease with Te mole fraction increases for monolayer and bulk samples, as shown in Figure a and b. Moreover, a red-shift and splits of E¹_{2g(W–Se)} and A_{1g(W–Se)}vibration modes with Te mole fraction decreases happen.



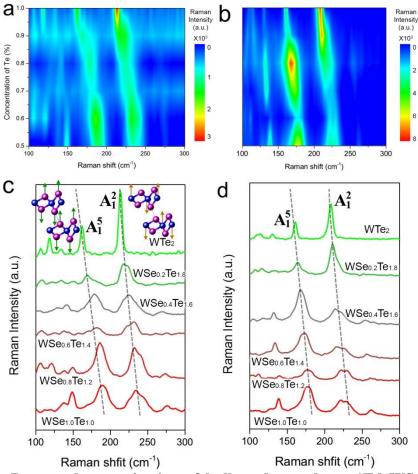


Figure 4. The Raman characterization of bulk and monolayer 1Td WSe_{2(1-x)}Te_{2x} (x = 0.6–1) alloys. Raman intensity of monolayer (a) and bulk (b)1Td WSe_{2(1-x)}Te_{2x} (x = 0.6–1) alloys with the different Te compositions. The intensities of the W–Te related vibration modes ($A^5_{1(W-Te)}$ and $A^2_{1(W-Te)}$) uniformly decrease with the concentration of Te increases from x = 0.6 to 1 for monolayer and bulk. Raman spectra of monolayer (c) and bulk (d) 1Td WSe_{2(1-x)}Te_{2x} (x = 0.6–1) alloys are shown, which show that the $A^5_{1(W-Te)}$ and $A^2_{1(W-Te)}$ vibration modes make a red-shift and become sharp with the concentration of Te increases from x = 0.6 to 1.



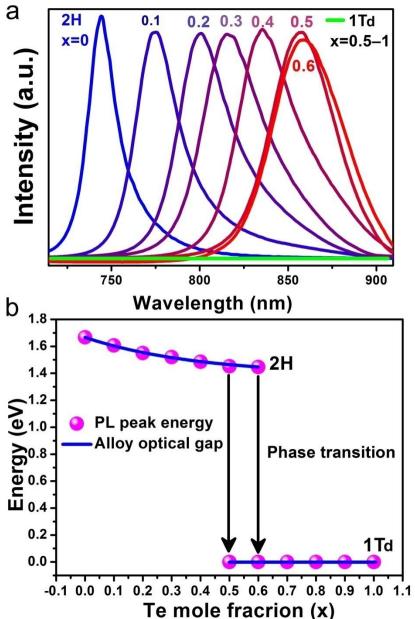
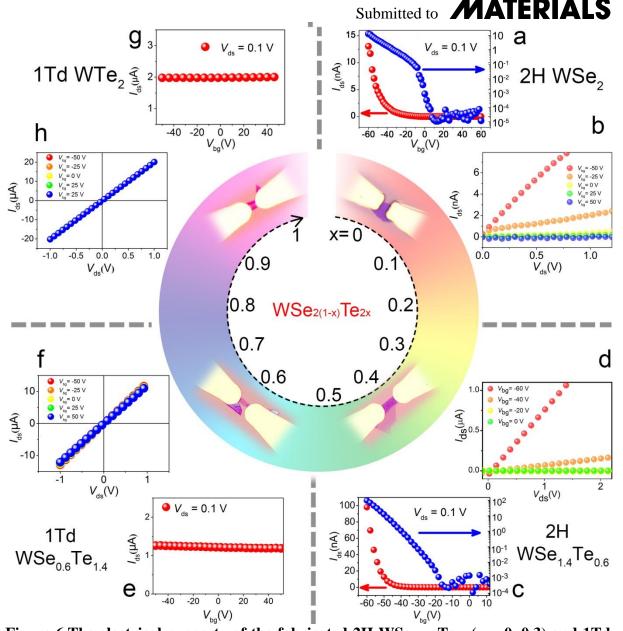


Figure 5. The photoluminescence (PL) spectra of monolayer WSe_{2(1-x)}Te_{2x} (x = 0–1.0) alloys. (a)the PL spectrum of the composition monolayer 2H WSe_{2(1-x)}Te_{2x} (x = 0–0.6) alloys. (b)the PL measurements of the composition monolayer 1Td WSe_{2(1-x)}Te_{2x} (x = 0.5–1.0) alloys. (c)composition-dependents (x) bandgaps of the monolayer WSe_{2(1-x)}Te_{2x} (x = 0–0.6) alloys.



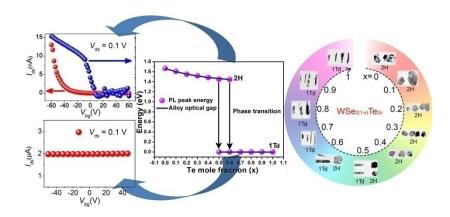
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Figure 6.The electrical property of the fabricated 2H WSe_{2(1-x)}Te_{2x} ($\mathbf{x} = \mathbf{0}, \mathbf{0}.3$) and 1Td WSe_{2(1-x)}Te_{2x}(($\mathbf{x} = \mathbf{0}.7, \mathbf{1}$) bilayer FET. Gating response (I_{ds} – V_{bg}) with a source–drain voltage (V_{ds}) of 0.1 V and the current–voltage (I_{ds} – V_{ds}) curves with different bottom gate voltage of 2H WSe₂ (a and b), 2H WSe_{1.4}Te_{0.6} (c and d), 1Td WSe_{0.6}Te_{1.4}(e and f), and 1Td WTe₂(g and h)bilayer FETs, whose optical images of the fabricated device are shown in the circular ring, respectively.



TOC

The metal-semiconductor phase-transition in the TMD ternary monolayer was achieved by doping Te into WSe₂ (WSe_{2(1-x)}Te_{2x}, where $x = 0 \sim 100\%$). Controlling the Te concentration leads to two distinct phases: semiconducting 2H ($x \le 60\%$) and metallic 1Td phase ($x \ge 50\%$). The optical band gaps of the WSe_{2(1-x)}Te_{2x} monolayer can be tuned from 1.67 eV to 1.44 eV (2H semiconductor) and drop to 0 eV (1Td metal), which open up an exciting opportunity in functional electronic/optoelectronic devices.



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